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Temperature-dependent tunneling electroresistance in Pt/BaTiO$_3$/SrRuO$_3$ ferroelectric tunnel junctions

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Tunneling electroresistance of Pt/BaTiO$_3$/SrRuO$_3$ ferroelectric tunnel junctions is investigated as a function of temperature. Two distinct resistance states that are dependent on polarization direction in the BaTiO$_3$ barrier layer and bipolar resistance switching are observed at various temperatures from 10 to 290 K. The ON/OFF current ratio of Pt/BaTiO$_3$/SrRuO$_3$ tunnel junctions increases monotonically with decreasing temperature above 50 K and saturates below 50 K. The enhanced tunneling electroresistance at low temperatures can be ascribed to the suppression of thermally assisted indirect tunneling, which is less sensitive to the polarization reversal of BaTiO$_3$ compared to the direct tunneling. © 2013 AIP Publishing LLC; [http://dx.doi.org/10.1063/1.4823580]

Significant technological advances have recently been achieved in the epitaxial growth of perovskite oxide thin films. Ferroelectricity is observed to exist even in films of only a few nanometers in thickness. This result makes it possible to realize ferroelectric tunnel junctions (FTJs), which are prototype nonvolatile memory elements composed of two metal electrodes separated by an ultrathin ferroelectric layer. The ultrathin ferroelectric layer serves as a potential barrier and allows direct quantum mechanical tunneling. The barrier height seen by the tunneling electrons can be electrically modulated via polarization reversal in the ferroelectric barrier. This phenomenon gives rise to electrical switching of the tunneling resistance between low (ON) and high (OFF) levels, i.e., tunneling electroresistance.

The ON/OFF ratio of FTJs varies over a few orders of magnitude as the polarization value, the thickness of ferroelectric barriers, and the screening length of electrodes are changed, in agreement with predictions by Zhuravlev and co-workers. In experiment, a direct correlation between polarization reversal and tunneling electroresistance has been demonstrated by means of scanning probe microscopy, employing conductive-tips as top electrodes, in several nanometer-thick BaTiO$_3$ (BTO) and PbTiO$_3$ layers grown on metallic perovskite oxides, such as (La,Sr)MnO$_3$ (LSMO) and SrRuO$_3$ (SRO). Repetitive switching between two distinct resistance values and good data retention for up to 10 yr have been achieved in FTJs at room temperature using BTO, Pb(Zr,Ti)O$_3$, and BiFeO$_3$ as barriers. These results reveal the significant potential utility of FTJs in nonvolatile memory applications with the advantages of non-destructive resistive readout, simple device architecture, and high density data storage.

However, it is well known that defects are present in ferroelectric thin films, and these increase the leakage currents and may result in significant degradation in overall performance of ferroelectric random access memories and ferroelectric field effect transistors. These defects may also exist in ultrathin ferroelectrics and, as a result, deteriorate resistance switching properties of FTJs. In this work, we report temperature-dependent tunneling electroresistance of Pt/BTO/SRO FTJs from 10 to 290 K. An increased ON/OFF current ratio is observed with decreasing temperature. This result is ascribed to the suppression of phonon-assisted indirect tunneling through localized defects present in the ferroelectric barriers.

Epitaxial BTO/SRO bilayers were deposited on (001) plane of single crystal pseudocubic DyScO$_3$ substrates by pulsed laser deposition using a KrF excimer laser ($\lambda = 248$ nm, Coherent COMPexPro205), monitored in situ by reflection high energy electron diffraction (RHEED, STAIB Instrumente GmbH). The DyScO$_3$ substrates were etched by NH$_4$F...
buffered-HF solution and then annealed at 1050 °C for 2 h in flowing O2 to form a single-termination step-terrace surface. 12-nm thick SRO electrodes were deposited with 2.5 J/cm² laser energy density at 4 Hz repetition, keeping the substrate temperature at 700 °C and the O2 pressure at 0.05 mbar. BTO layers were deposited with 1.5 J/cm² laser energy density and 2 Hz repetition rate at 750 °C and 0.005 mbar O2 pressure. The thickness of the BTO barrier layer was set at 12 unit-cells (u.c.) by counting the number of RHEED intensity oscillations, as shown in Fig. 1. Clear oscillations of the RHEED intensity (u.c.) by counting the number of RHEED intensity oscillations, as shown in Fig. 1. Clear oscillations of the RHEED intensity reveal layer-by-layer growth of the BTO layer. This growth mode maintains the step-terrace morphology of the substrate layers.

The write pulse of $+0.5$ V biased tip over the two domains shown in Fig. 2(b). As expected, a clear current contrast with respect to the polarization direction of BTO is observed, as shown in Fig. 2(c). The down domain (the ON state) shows a larger tunneling current than that of the up domain (the OFF state), as also seen in the polarization-dependent tunneling resistance of ultrathin BTO and PbTiO3 grown on SrTiO3 substrates.

Pt top electrodes were deposited on BTO layers to produce FTJs. Fig. 3 shows resistance switching properties of the Pt/BTO/SRO tunnel junctions under bipolar pulse cycling. The write pulse of $+3.0$ and $-2.0$ V were applied alternately on the Pt electrode to switch the polarization of BTO barrier. After each write pulse, the tunneling resistance was read by a $+0.1$ V pulse. As shown, a repetitive bipolar resistance switching is achieved at room temperature with an ON/OFF ratio of $\sim 10$.

The direct tunneling conductance of Pt/BTO/SRO fluctuates below 1% over the temperature region of 10–290 K according to the Stratton temperature correction factor $\frac{C}{\sin CT}$, where $C \propto 10^{-5}d/\sqrt{\Phi}$ with the barrier width (d) in nanometers and the barrier height (Φ) in eV. (Here, the barrier heights are taken from the fits shown in Figs. 4(e) and 4(f).) Since the direct tunneling process is almost temperature independent, the I-V characteristics of Pt/BTO/SRO tunnel junctions are measured as a function of temperature to separate the possible contribution from thermally activated conduction. As shown in Figs. 4(a) and 4(b), the currents of the ON and the OFF states decrease with decreasing temperature. Correspondingly, the ON/OFF ratio, shown in Fig. 4(c), increases with decreasing temperature from 290 to 50 K and saturates below 50 K. The significant temperature dependence of tunneling electroresistance in the Pt/BTO/SRO tunnel junction implies thermally activated contributions in parallel with direct tunneling. A similar phenomenon has also been observed in LSMO/(La,Ca)MnO3/BTO/LSMO FTJs, where the conductance increases significantly with increasing temperature, accompanied with a smearing of the tunneling electroresistance. Yin et al. pointed out that, in addition to the direct tunneling, thermally activated indirect tunneling also occurs in LSMO/(La,Ca)MnO3/BTO/LSMO FTJs. This kind of tunneling originates from electron hopping through chains of localized states inside the barrier.
layer and is associated with the emission (or absorption) of phonons.18–21 This phonon-assisted indirect tunneling is strongly temperature dependent and less sensitive to polarization reversal, in contrast to the direct tunneling. This tunneling mode has also been frequently observed in magnetic tunnel junctions18,19,21,22 and can be described by the Glazman-Matveev (GM) model.18,21–23 The temperature-dependent conductance \( G \) of a tunnel junction through \( N \geq 1 \) localized states is given by

\[
G = G_{DT} + \sum_{N=1}^{\infty} a_N T(N/2, \frac{2d}{N+1} x),
\]

where \( G_{DT} \) represents the direct tunneling term and \( a_N \propto \exp[-2d/(N+1)x] \) are constants dependent on the radius of the localized states \( x \) and the barrier width \( d \). Note that the expression for \( G(T) \) is applicable for \( eV \ll k_B T \) and is valid when both \( eV \) and \( k_B T \) are smaller than the barrier height.18,21 With the barrier height close to 1 eV in Pt/BTO/SRO, this expression can be used over the entire temperature range of 10–290 K when the voltage \( V \) is close to 0. As shown in Fig. 4(d), the conductance of the ON and the OFF states at zero bias, i.e., \( \frac{dI}{dV} \big|_{V=0} \), decreases by over about two orders of magnitude with decreasing temperature. The temperature-dependent conductance data from 290 to 50 K can be well fitted using the GM expression with \( N = 4 \).

Owing to the gradual suppression of the less polarization-sensitive phonon-assisted indirect tunneling, the ON/OFF ratio of Pt/BTO/SRO increases monotonically from 290 to 50 K. As the temperature is further decreased, the ON and the OFF conductance changes little. Correspondingly, the ON/OFF ratio saturates. These results imply that direct tunneling may be predominant in electronic transport of Pt/BTO/SRO junctions below 50 K, since the indirect tunneling is substantially suppressed. The I-V curves at 50 and 10 K are almost identical and can be well fitted using the formula for direct tunneling proposed by Gruverman et al. based on a trapezoidal shape potential barrier,6 as shown in Figs. 4(e) and 4(f). The barrier heights at the Pt/BTO and BTO/SRO interfaces are 0.89 and 0.62 eV, respectively, for the ON state. After polarization switching, the barrier heights change to 1.13 and 0.51 eV, respectively, for the OFF state. The modulation of barrier height is 0.065 eV due to polarization reversal, which yields an ON/OFF ratio of ~30 below 50 K, 3 times larger than that at room temperature. The barrier profiles and their polarization dependences in Pt/BTO/SRO tunnel junctions agree well with the previous results reported in the literature.6,8,10

In summary, the tunneling electroresistance of Pt/BTO/SRO FTJs has been investigated as a function of temperature. The existence of two distinct resistance states upon polarization reversal is clearly observed. Typical bipolar resistance switching with an ON/OFF ratio of ~10 is achieved at room temperature. As temperature decreases, the currents through the Pt/BTO/SRO FTJs decrease by over about two orders of magnitude from 290 to 50 K. The indirect tunneling conduction, resulting from the phonon-assisted electron hopping through defect chains in the BTO barrier, is found to be responsible for the significantly temperature-dependent I-V characteristics of Pt/BTO/SRO. Direct tunneling conduction is observed below 50 K when defect-mediated tunneling currents are substantially suppressed. The ON/OFF ratio increases correspondingly by a factor of 3 with decreasing temperature. These results suggest that the reduction of defect density and then the suppression of indirect tunneling can greatly enhance the performance of FTJs and thus is a prerequisite for their future applications in non-destructive readout nonvolatile resistive ferroelectric memories.

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FIG. 4. Temperature-dependent tunneling electroresistance of the Pt/BTO/SRO FTJ, where write pulses of +3.0 and −2.0 V are applied to set the junction to the ON and the OFF states, respectively. Semi-log I-V curves of the ON (a) and the OFF (b) states measured at various temperatures. (c) ON/OFF current ratio at +0.1 V as a function of temperature. (d) Conductance at zero bias as a function of temperature. The solid lines are fits to the GM model. ON (e) and OFF (f) I-V curves at 10 K, where the solid lines are fits to the direct tunneling model.
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